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1722

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Tsuyoshi NISHIZAWA

Group Art Unit: 1722

Application No.: 10/561,957

Docket No.: 126273

Filed: December 22, 2005

For: METHOD FOR PRODUCING SILICON EPITAXIAL WAFER AND SILICON
EPITAXIAL WAFER

REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

William P. Berridge
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WPB:TMN/crh

Date: July 19, 2006

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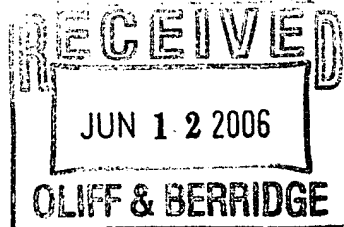


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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/561,957	12/22/2005	1722	950	126273	12	21	3

25944
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CONFIRMATION NO. 3542

FILING RECEIPT



OC000000019134068

Date Mailed: 06/07/2006

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

Tsuoyoshi Nishizawa, Fukushima, JAPAN;

Power of Attorney: The patent practitioners associated with Customer Number **25944**.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/08725 06/21/2004

Foreign Applications **JAPAN 2003-182615 06/26/2003**

If Required, Foreign Filing License Granted: 06/06/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/561,957**

Projected Publication Date: 09/14/2006

Non-Publication Request: No

Early Publication Request: No

Title

Method for producing silicon epitaxial wafer and silicon epitaxial wafer

Preliminary Class

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